IN THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Previously Amended) A component of a vacuum deposition apparatus, comprising:

a component body; and

a spray deposit coated on a surface of the component body and having surface roughness in which a mean spacing S of tops of local peak of profile is in a range from 50 to 150 μm, a distance from a mean line to a bottom of profile valley line Rv is in a range from 20 to 70 μm, and a distance from a mean line to a top of profile peak line Rp is in a range from 20 to 70 μm.

2. (Original): The component as set forth in claim 1:

wherein the spray deposit comprises a coat comprising metal of which thermal expansion coefficient is different by 15 x 10^{-6}/K or less from that of a material deposited by the vacuum deposition apparatus.

3. (Original): The component as set forth in claim 1:

wherein the spray deposit comprises a coat comprising metal of which thermal expansion coefficient is different by 20 x 10^{-6}/K or less from that of the component body.

4. (Previously Amended) The component as set forth in claim 1:

wherein the spray deposit comprises coats of two or more layers of different materials.

5. (Previously Amended) The component as set forth in claim 4:

wherein the spray deposit comprises a stress relief layer formed on the component body and comprising at least one of Al, Cu, or Ni or alloys of Al, Cu, or Ni, and a thermal expansion relief layer formed on the stress relief layer and comprising metal of which thermal expansion coefficient is different by 10×10^{-6}/K or less from that of a material deposited by the vacuum deposition apparatus.

6 (Original): The component as set forth in claim 1:

wherein the spray deposit comprises at least one coat selected from an Al base spray deposit of Vickers hardness of Hv 30 or less, a Cu base spray deposit of Vickers hardness of Hv 100 or less, a Ni base spray deposit of Vickers hardness of Hv 200 or less, a Ti base spray deposit of Vickers hardness of Hv 300 or less, a Mo base spray deposit of Vickers hardness of Hv 300 or less, and a W base spray deposit of Vickers hardness of Hv 500 or less.

7. (Original): The component as set forth in claim 1:

wherein the spray deposit has a thickness in the range from 50 to 500 μm.

Claims 8 -17 (Canceled):

18. (Original): A vacuum deposition apparatus, comprising: a vacuum chamber;

a sample holder holding a sample to be deposited and disposed in the vacuum chamber;

a deposition material source disposed in the vacuum chamber facing to the sample holder;

a source holder holding the deposition material source; and a preventive component disposed in the surroundings of the sample holder or the source holder;

wherein at least one selected from the sample holder, the source holder and the preventive component comprises the component for a vacuum deposition apparatus set forth in claim 1.

Sub C1 B1 Cont'd

19. (Original): The vacuum deposition apparatus as set forth in claim 18:

wherein the spray deposit formed on the surface of the component for a vacuum deposition apparatus comprises a coat containing at least one of metal forming the deposition material source.

20. (Original): The vacuum deposition apparatus as set forth in claim 18:

wherein the deposition apparatus is a sputtering apparatus.

Claims 21-23 (Canceled).

24. (Previously Amended) A target apparatus, comprising:

a target body; and

a spray deposit coated on a non-erosion area of the target body and having surface roughness in which a mean spacing S of tops of local peak of profile is in a range from 50 to 150 μm, a distance from a mean line to a bottom of profile valley line Rv is in a range from 20 to 70 μm, and a distance from a mean line to a top of profile peak line Rp is in a range from 20 to 70 μm.

25. (Previously Amended) A target apparatus, comprising:

Sub C1

a target; and

a backing plate comprising a backing plate body holding the target, and a spray deposit coated on a surface of the backing plate body and having surface roughness in which a mean spacing S of tops of local peak of profile is in a range from 50 to 150 μm, a distance from a mean line to a bottom of profile valley line Rv is in a range from 20 to 70 μm, and a distance from a mean line to a top of profile peak line Rp is in a range from 20 to 70 μm.

Cont'd

26-27 (Canceled).